In the Claims:

1. (Currently amended) A semiconductor light emitting device of a II-VI group compound semiconductor formed on a compound semiconductor substrate and ~~having~~ comprising an active layer between an n-type cladding layer and a p-type cladding layer, further comprising

an i-type semiconductor barrier layer consisting of a single monolayer of an i-type semiconductor material having a band gap larger than a band gap of said p-type cladding layer, provided between and respectively directly in contact with said active layer and said p-type cladding layer.

2. (Withdrawn) The semiconductor light emitting device according to claim 1, wherein

said light emitting device of the II-VI group compound is a ZnSe based light emitting device;

said n-type cladding layer is an n-type $Zn_{1-x}Mg_xS_ySe_{1-y}$ ($0 < x < 1$, $0 < y < 1$) layer; and

said p-type cladding layer is a p-type $Zn_{1-x}Mg_xS_ySe_{1-y}$ ($0 < x < 1$, $0 < y < 1$) layer.

3. (Original) The semiconductor light emitting device according to claim 1, wherein

magnitude of the band gap of said barrier layer is larger by 0.025 eV to 0.5 eV than the band gap of said p-type cladding layer.

4. (Previously presented) The semiconductor light emitting device according to claim 1, wherein

in the band gap of said barrier layer, energy of valence band is approximately the same as or higher than that of said p-type cladding layer, and energy of conductive band is larger than that of said p-type cladding layer.

5. (Original) The semiconductor light emitting device according to claim 1, wherein

said barrier layer is of a II-VI group compound semiconductor containing Be.

6. (Original) The semiconductor light emitting device according to claim 5, wherein

said barrier layer is of $Zn_{1-x-y}Mg_xBe_ySe$ ($0 \leq x + y \leq 1$, $0 < x$, $0 < y$).

7. (Withdrawn) The semiconductor light emitting device according to claim 1, wherein

said barrier layer is of $Zn_{1-x}Mg_xS_ySe_{1-y}$.

Claims **8 to 10** (Canceled).

11. (Original) The semiconductor light emitting device according to claim 1, wherein

said p-type cladding layer is formed of $(Zn_{1-x}Cd_xS)_{1-z}(MgS_{1-y}Se_y)_z$ (where x, y, z satisfy $0 < x \leq 1$, $0 \leq y \leq 1$, $0 \leq z < 1$).

12. (Original) The semiconductor light emitting device according to claim 1, wherein

thickness of said barrier layer is at least 5 nm and at most thickness of said active layer.

13. (Original) The semiconductor light emitting device according to claim 1, wherein

an n-type ZnSe single crystal substrate is used as said compound semiconductor substrate.

14. (Withdrawn) The semiconductor light emitting device according to claim 1, wherein

an n-type GaAs single crystal substrate is used as said compound semiconductor substrate.

15. (Withdrawn) The semiconductor light emitting device according to claim 1, wherein

in a stacked structure including said compound semiconductor substrate constituting said ZnSe based light emitting device, deviation between a peak of X-ray

diffraction of a plane orientation used as an index of distortion from said substrate and a peak of X-ray diffraction of said plane orientation from said stacked structure is at most 1000 seconds.

Claims **16 to 25** (Cancelled).

[RESPONSE CONTINUES ON NEXT PAGE]